



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Docket No. FIS920030183US1

Dureseti Chidambarao, et al.

Serial No.: 10/605,108

Group Art Unit: No. 2814

Filed: September 9, 2003

Examiner: Pham, Long

For: **METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI ON SI/GE  
SUBSTRATE**

U.S. Patent and Trademark Office  
Customer Window  
Randolph Building  
Alexandria, VA 22314

**PETITION AND FEE FOR EXTENSION OF TIME  
UNDER 37 C.F.R. 1.136**

Sir:

Applicant hereby petitions for a one-month extension of time to respond to the Office Action mailed on October 26, 2004 and Advisory Action mailed February 14, 2005. Please charge the amount of \$120.00 (37 C.F.R. 1.17(a)(1)) is to cover the extension of time fee, charge any deficiencies in payment and credit any overpayment to International Business Machines Corporation's deposit account no. 09-0458.

Respectfully submitted,

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